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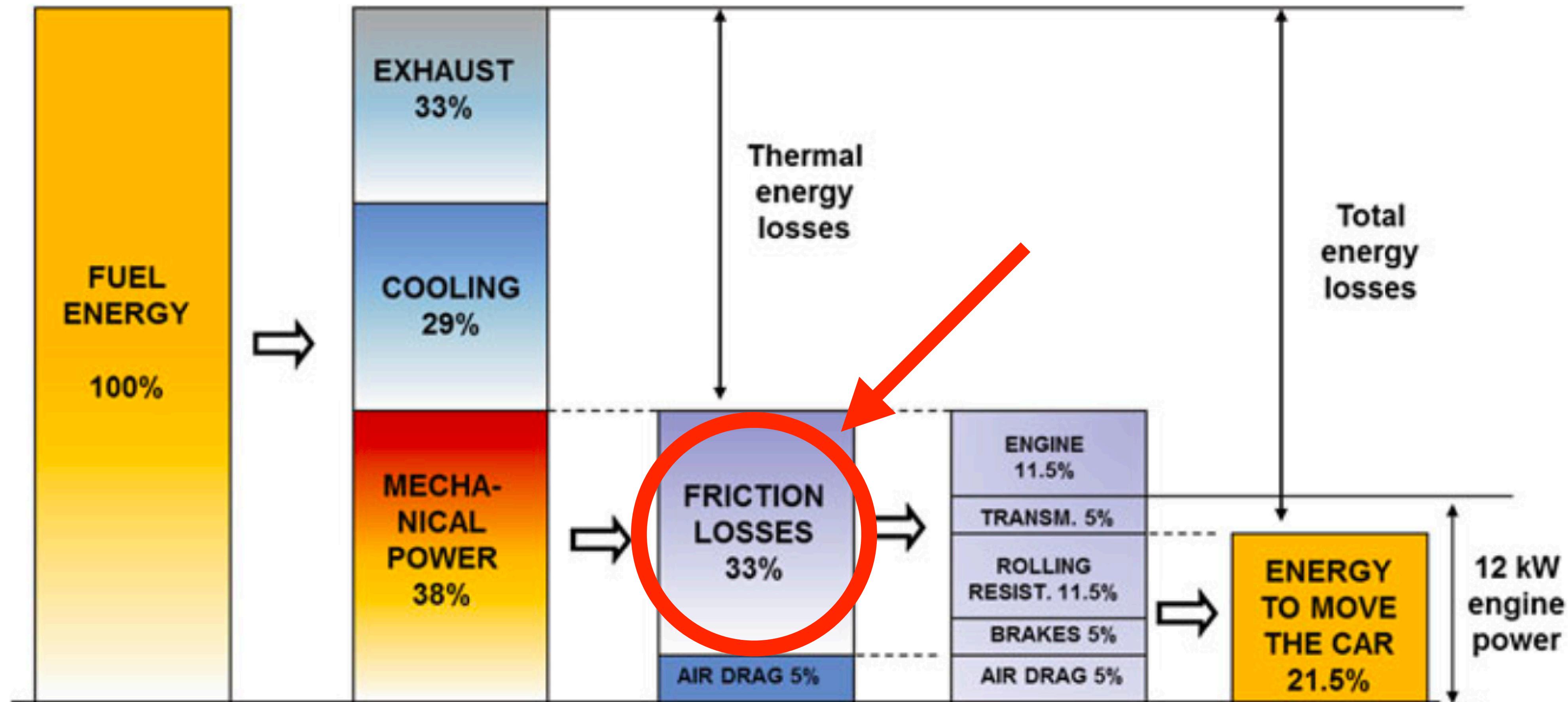
**Dipartimento di Scienze Chimiche**

**Corso di Laurea in Scienza dei Materiali**

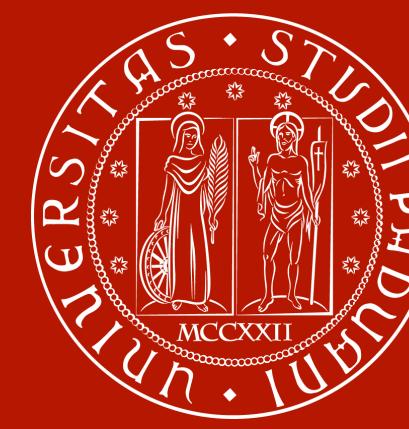
*Film sottili di DLC depositati attraverso tecniche PVD per applicazioni in ambito automotive*

Davide Saltarello - Matricola 1239019  
Padova, 18 luglio 2024

# FRICTION AND ENERGY LOSS



# DIAMOND LIKE-CARBON (DLC)

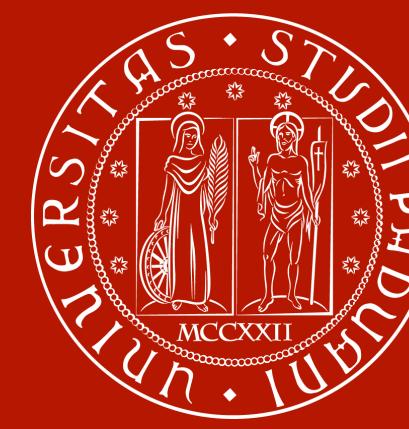


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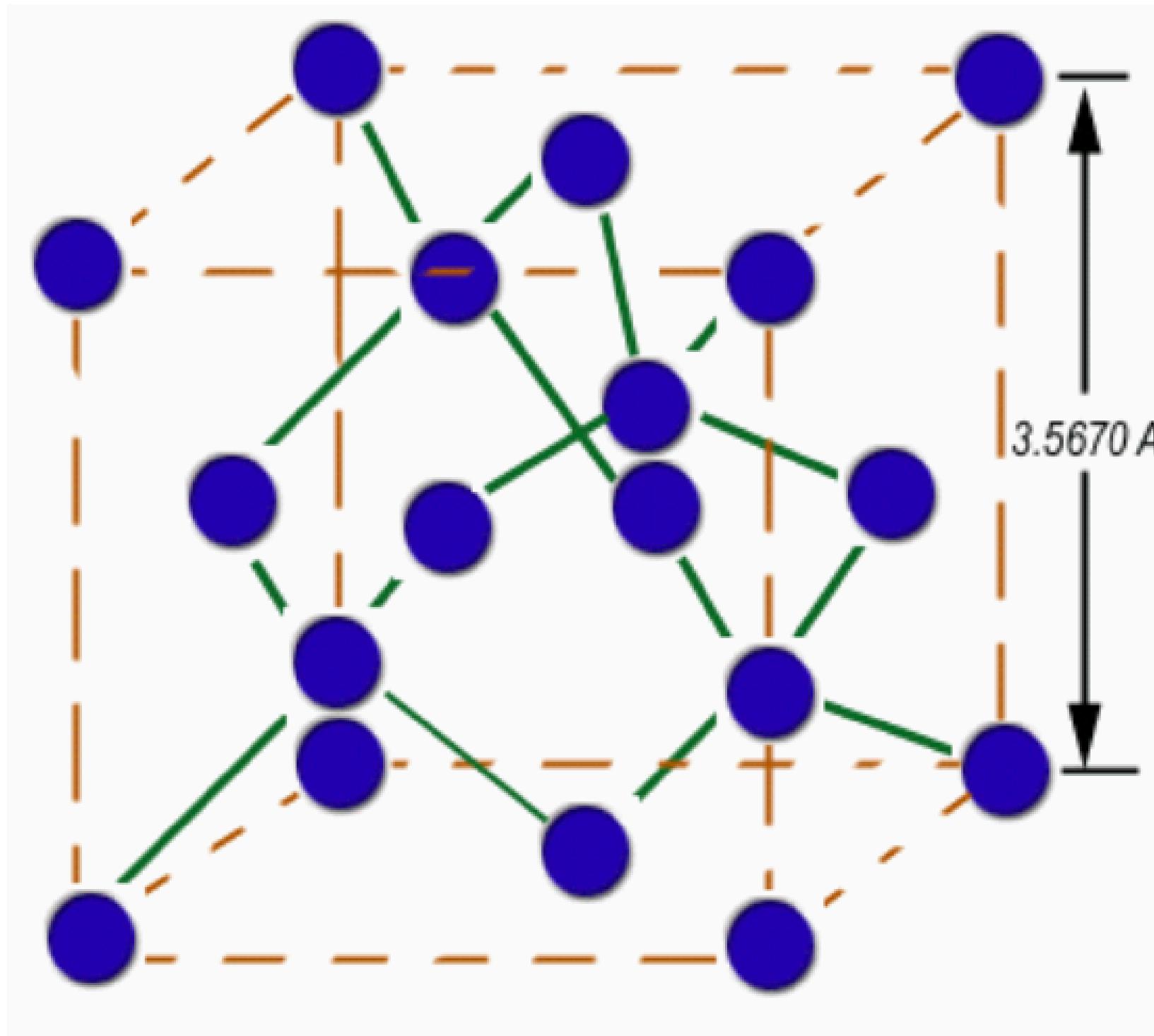


**Solid lubricant  
Amorphous  
Excellent tribological properties**

# DIAMOND LIKE-CARBON (DLC)



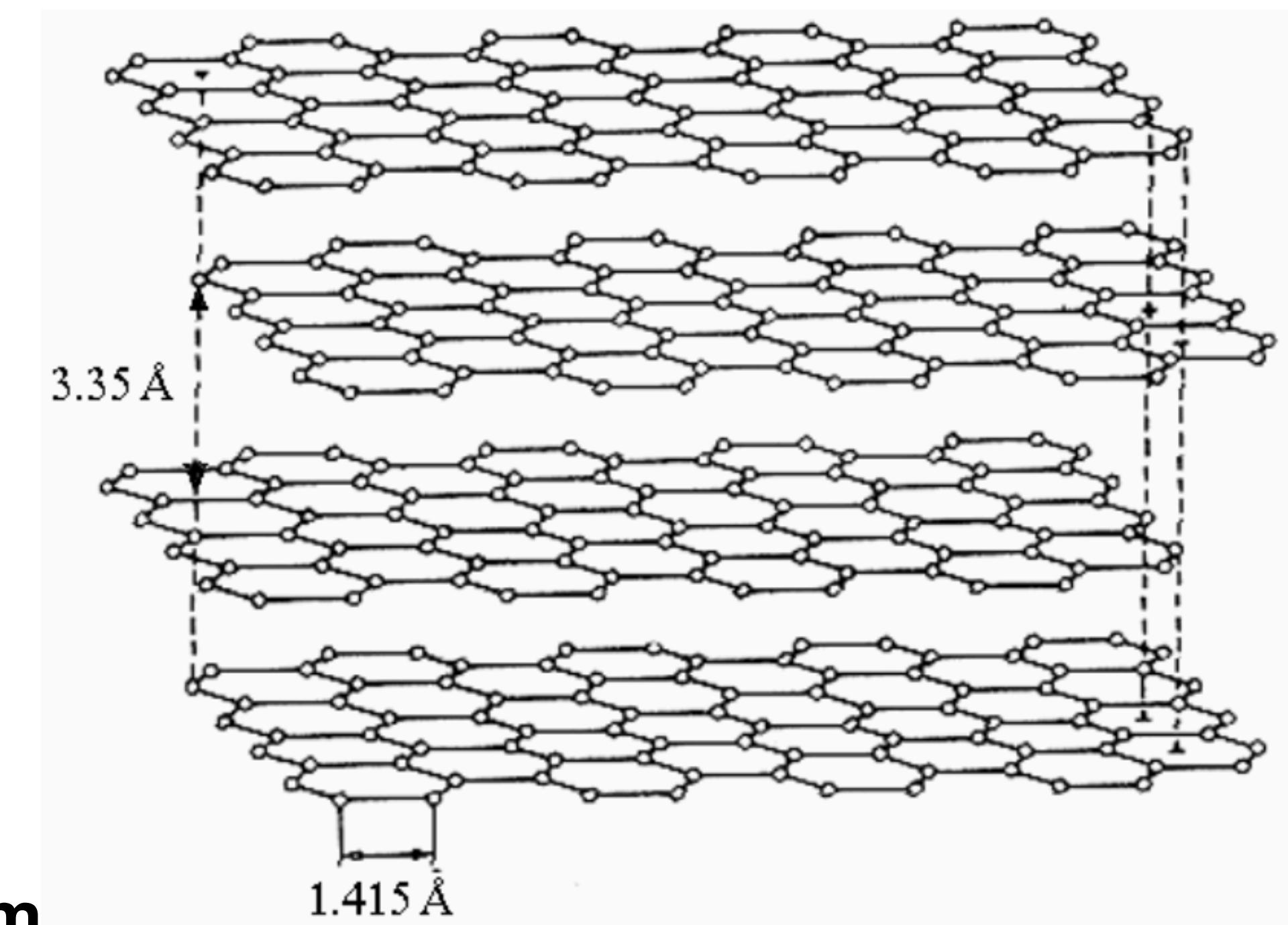
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+

**Thickness 0,01-2  $\mu\text{m}$**

$\text{Sp}^3$  (diamond)



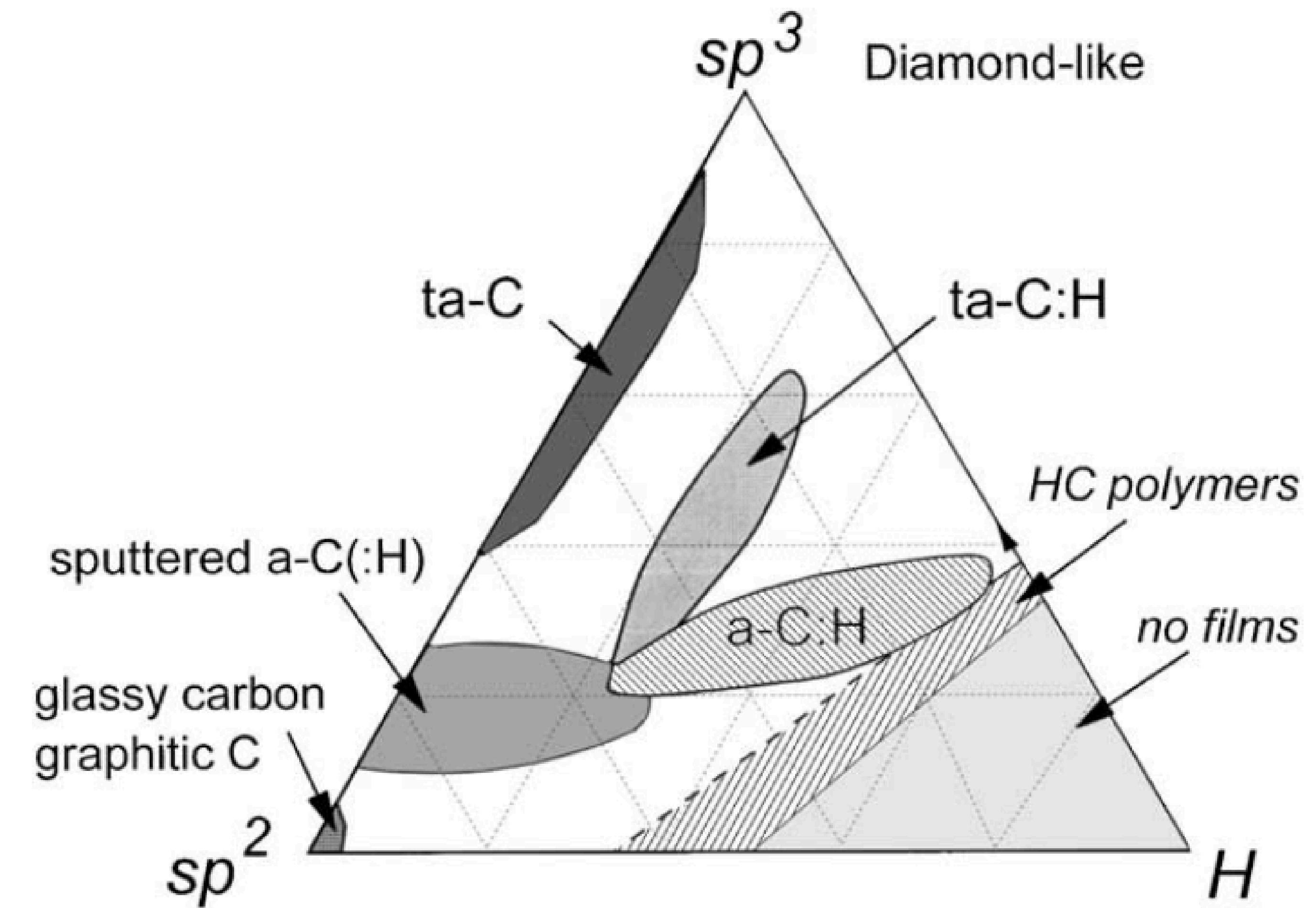
$\text{Sp}^2$  (graphite)

# TERNARY DIAGRAM

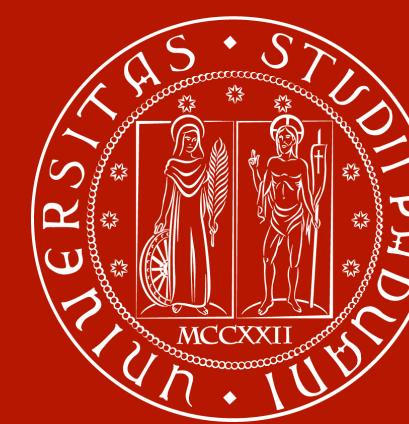


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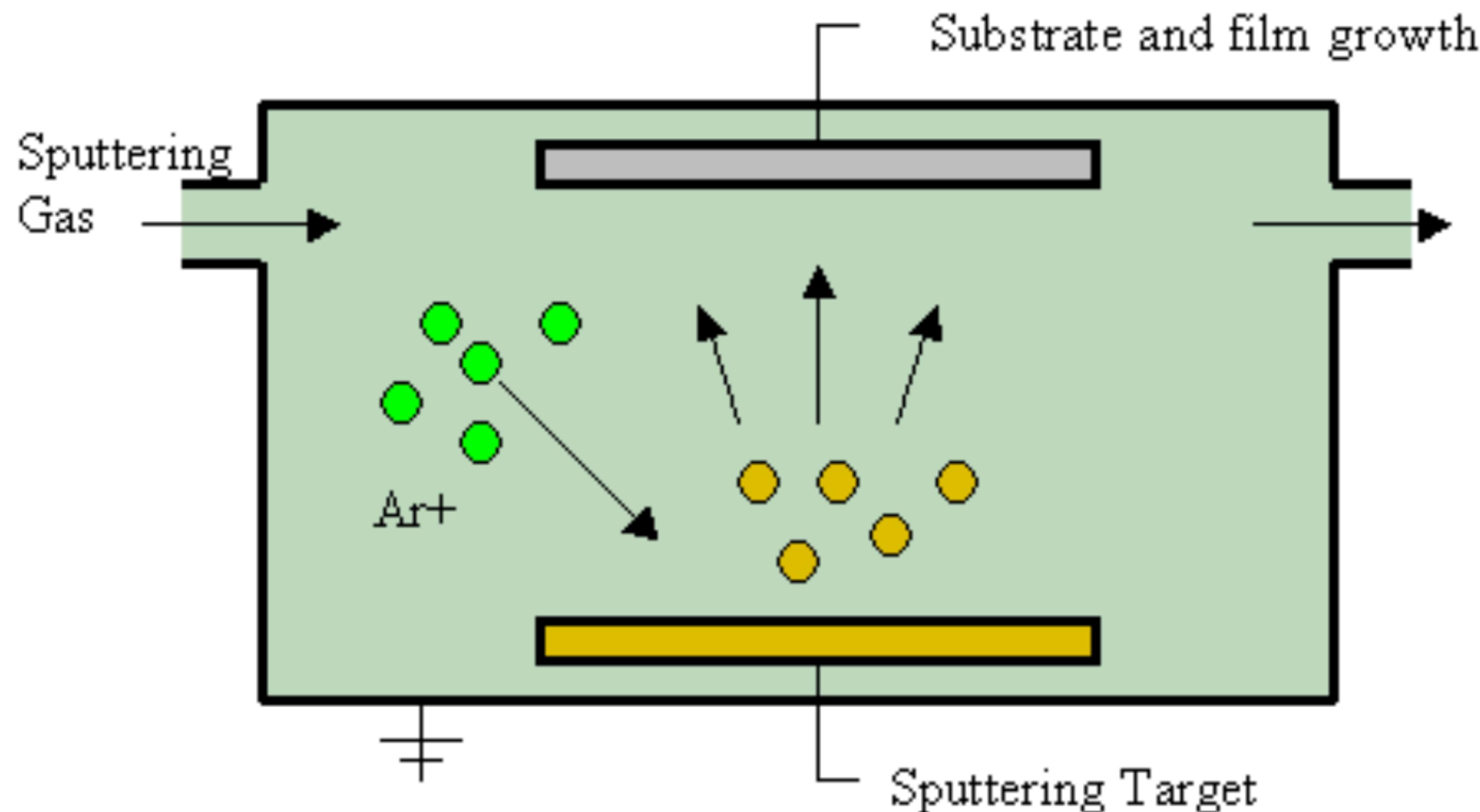
- ta-C ( $sp^3$  80-88%)
- ta-C:H ( $sp^3$  70% - H 30%)
- a-C:H ( $sp^3$  40-60% - H 30-50%)



# PVD - SPUTTERING

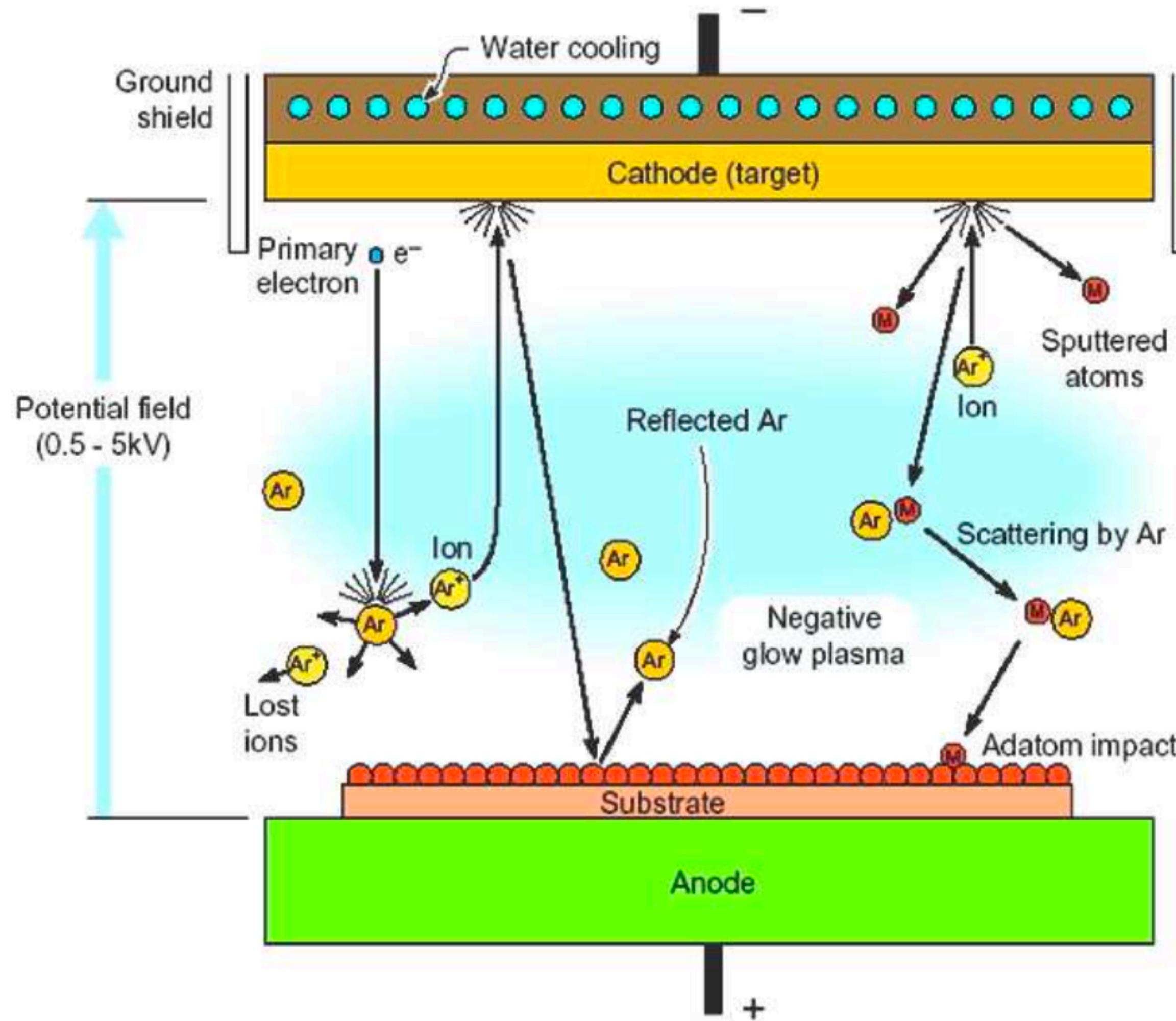


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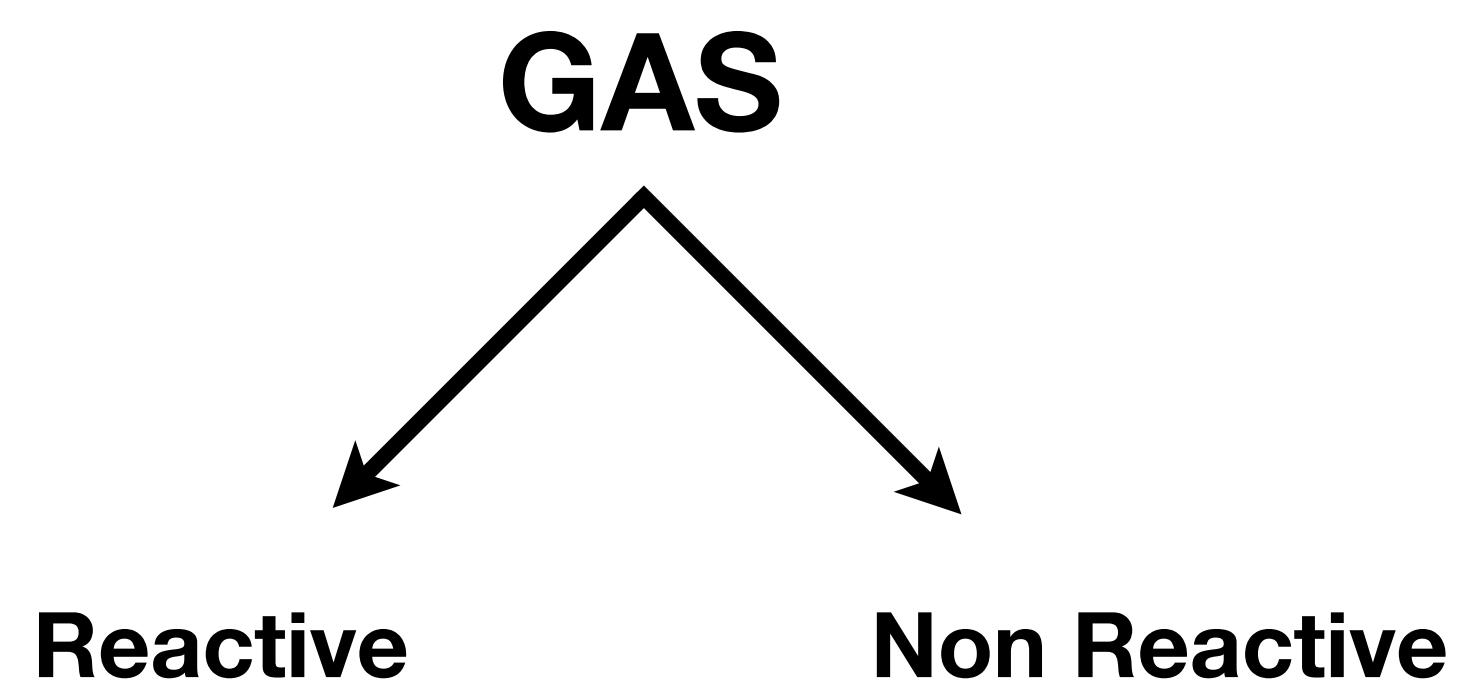


**Atomic ejection  
Kinetic Energy  
Threshold energy**

# DC SPUTTERING



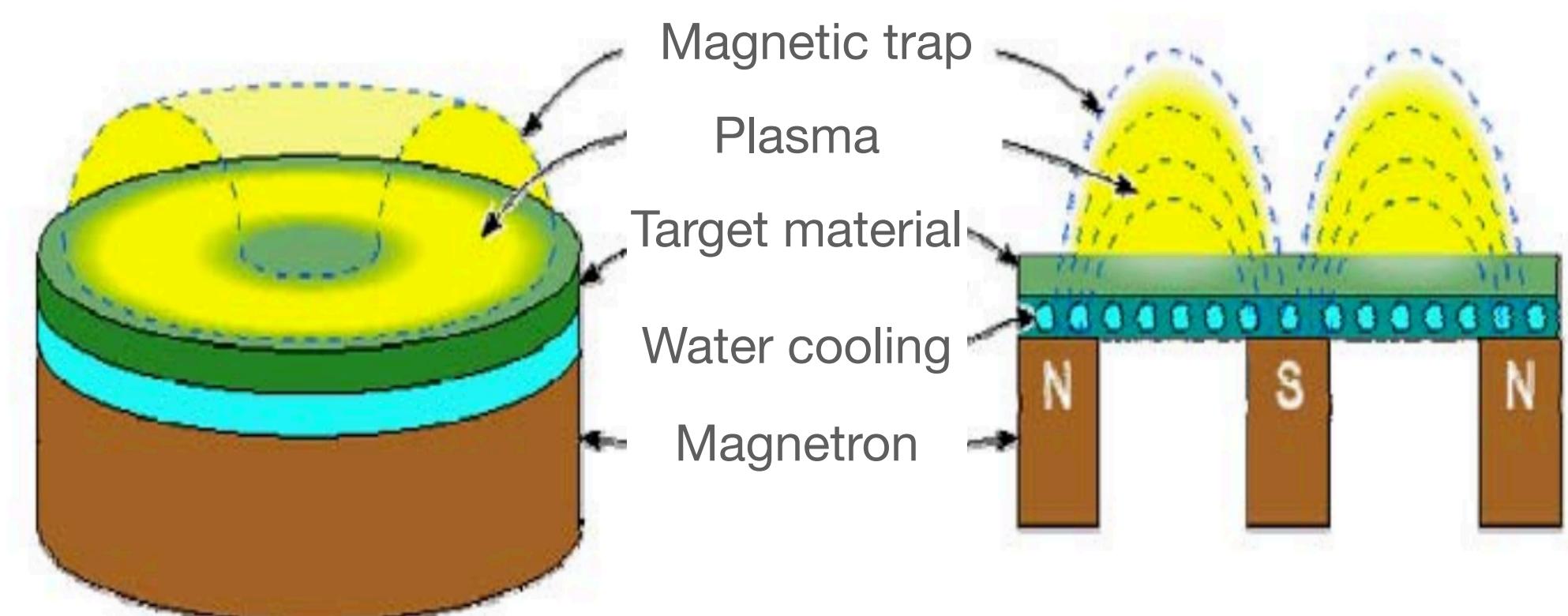
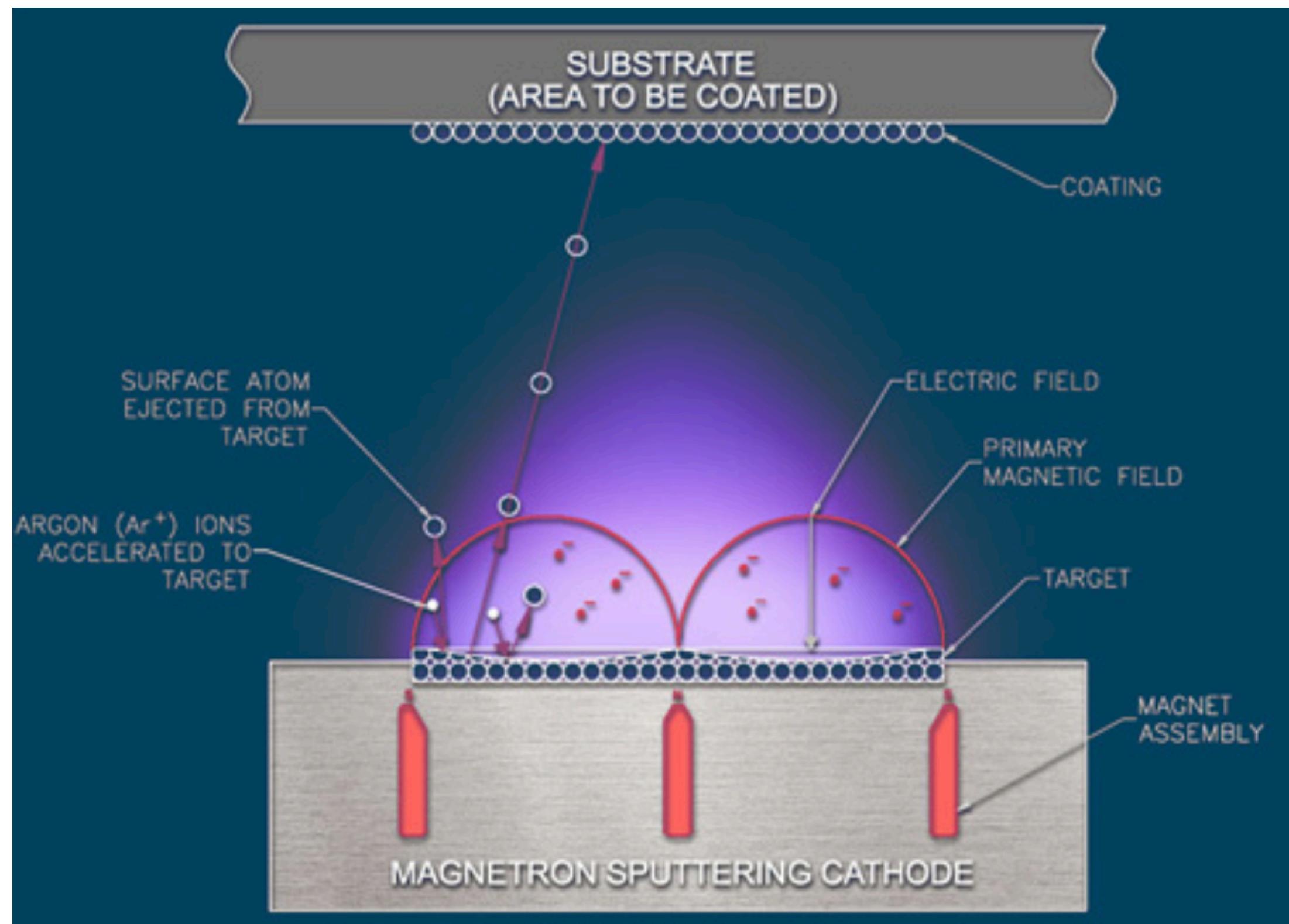
- Target (cathode)
- Substrate (anode)
- UHV ( $10^{-7}\text{ Pa}$ )
- $0,5 - 5\text{ kV}$



# MAGNETRON SPUTTERING (MS)



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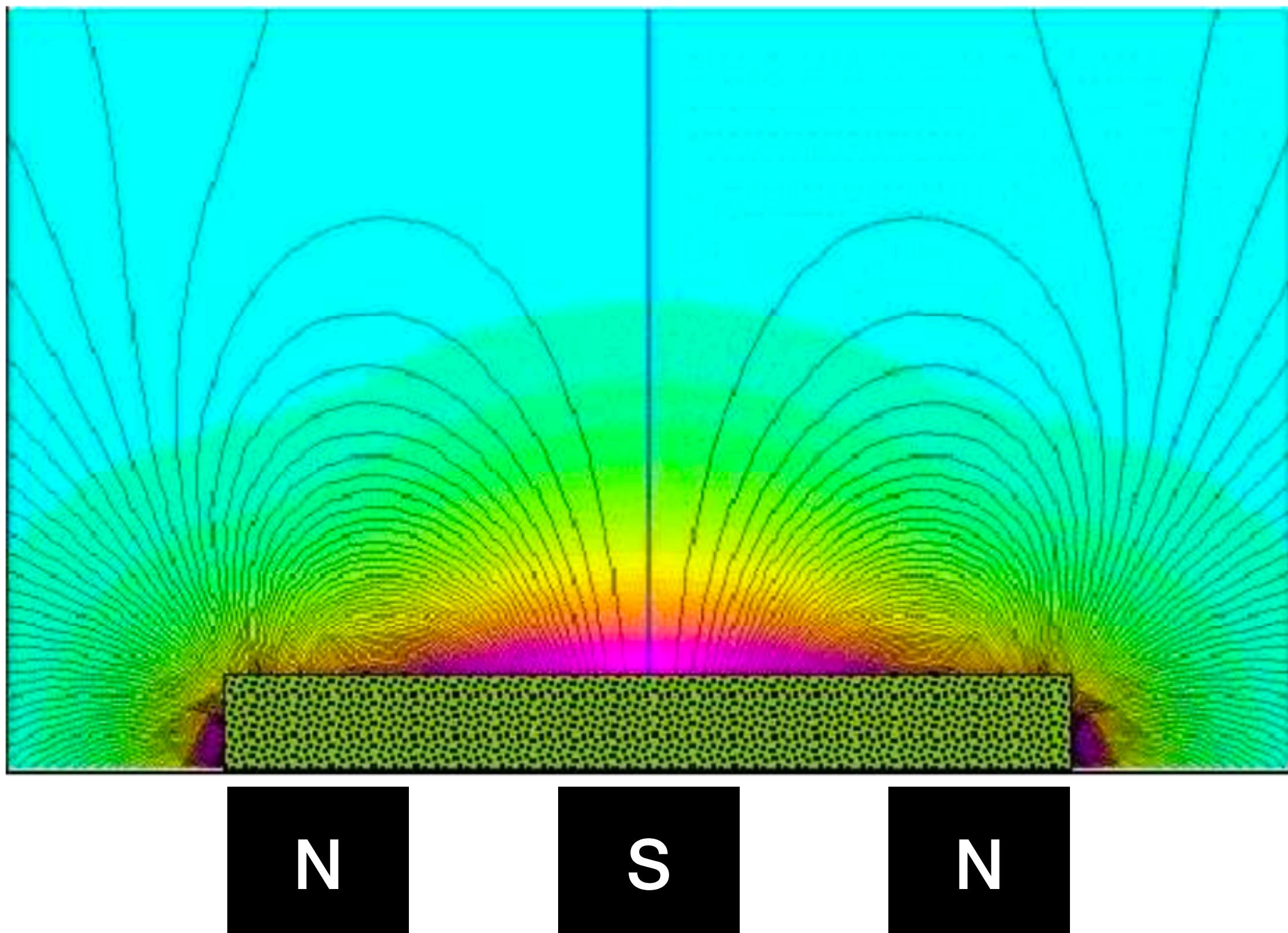
# MAGNETRON SETTING



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## 3 KIND OF MAGNETRON:

1. **BALANCED MAGNETRON**
2. UNBALANCED I
3. UNBALANCED II



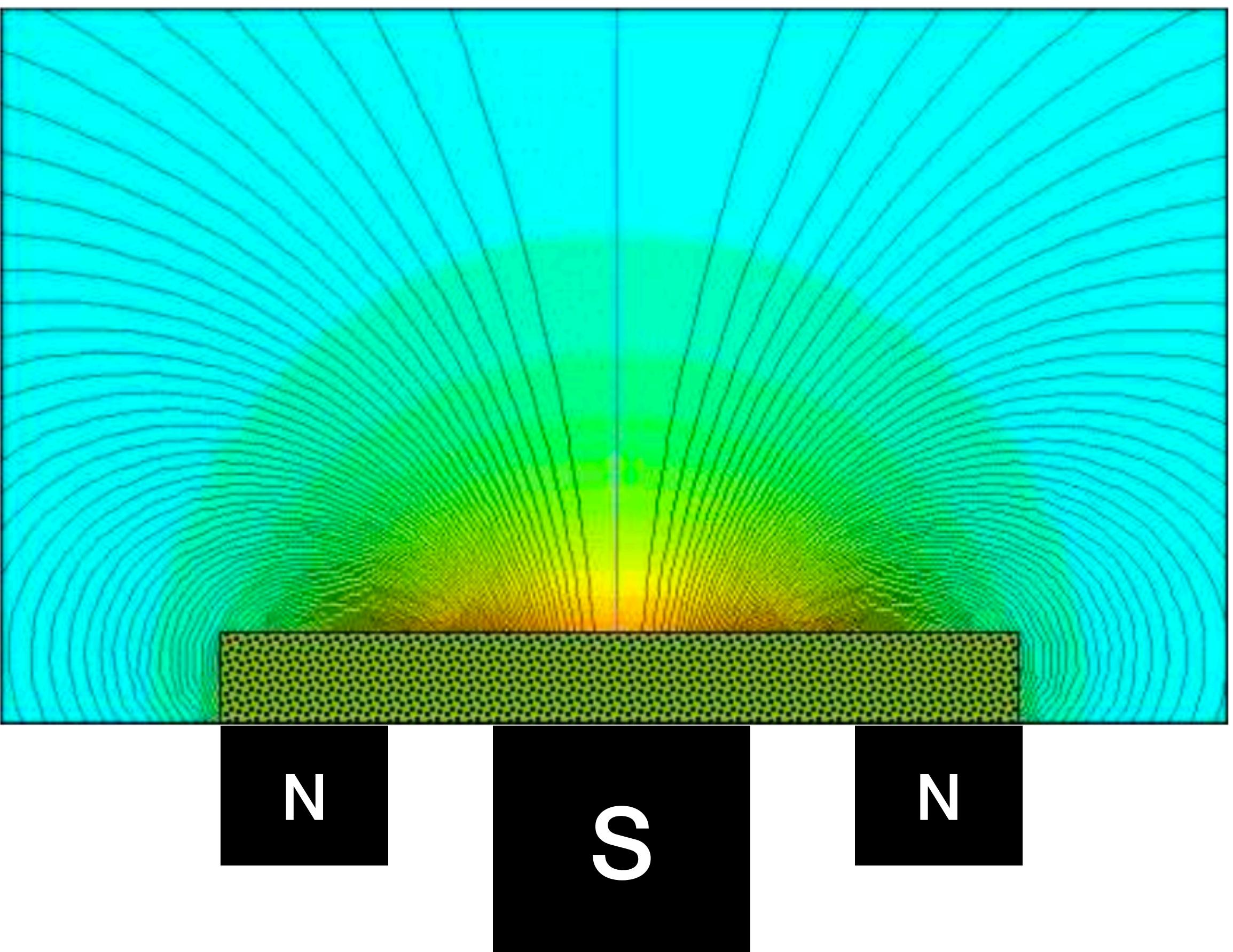
# MAGNETRON SETTING



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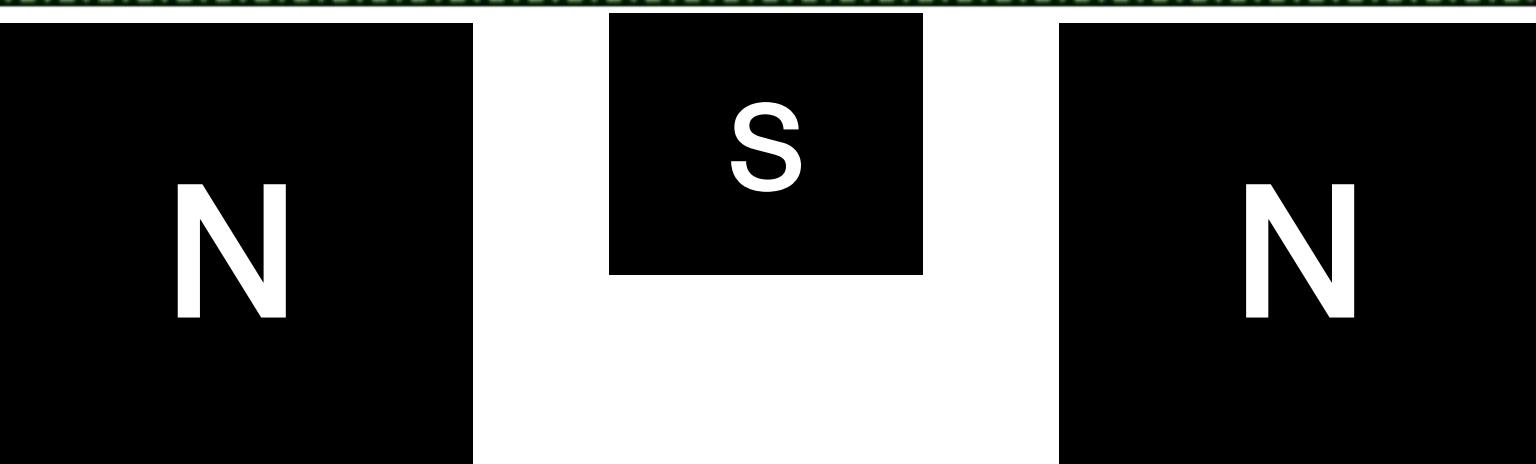
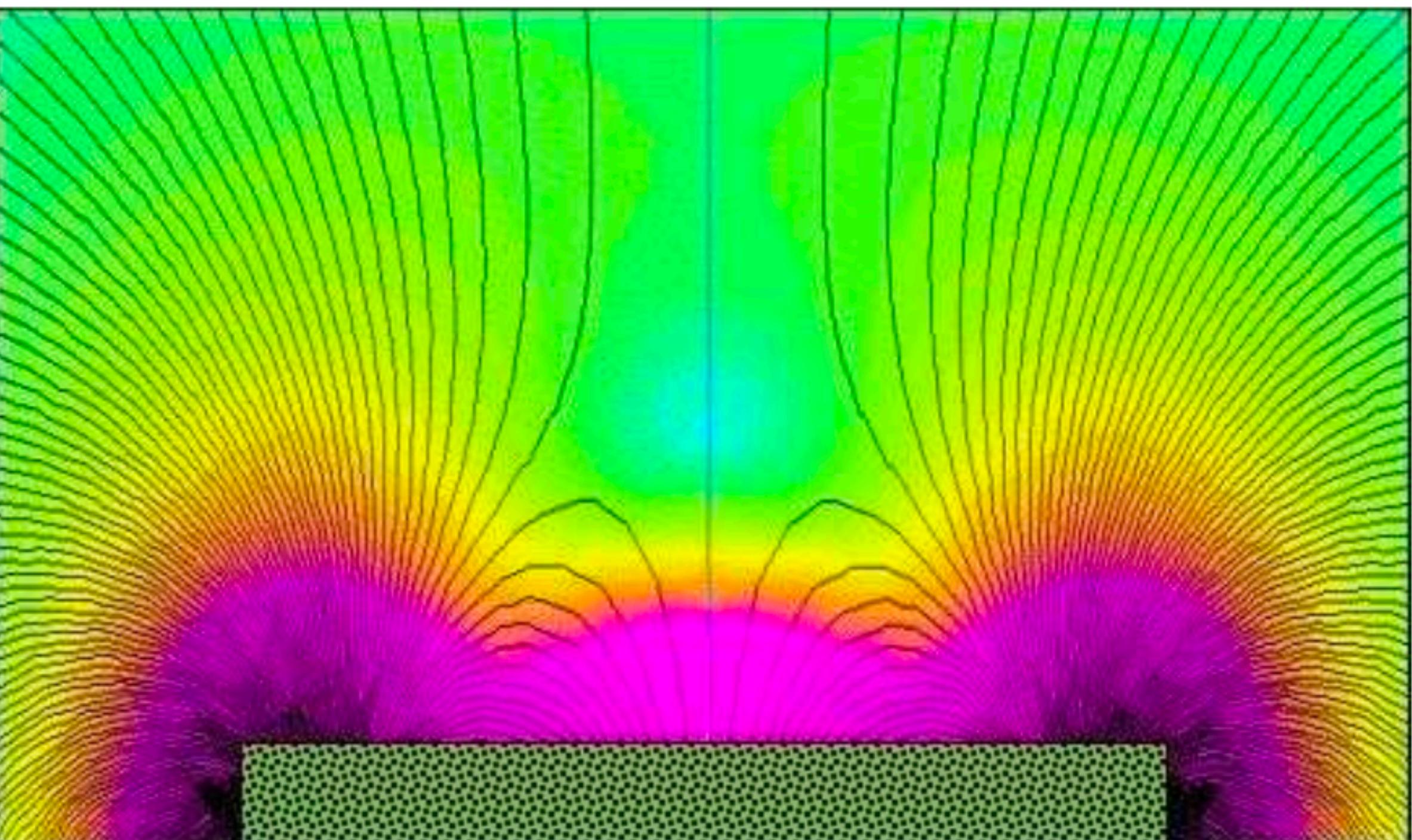
# MAGNETRON SETTING



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## 3 KIND OF MAGNETRON:

1. BALANCED MAGNETRON
2. UNBALANCED I
3. **UNBALANCED II**



### **Experimental parameters:**

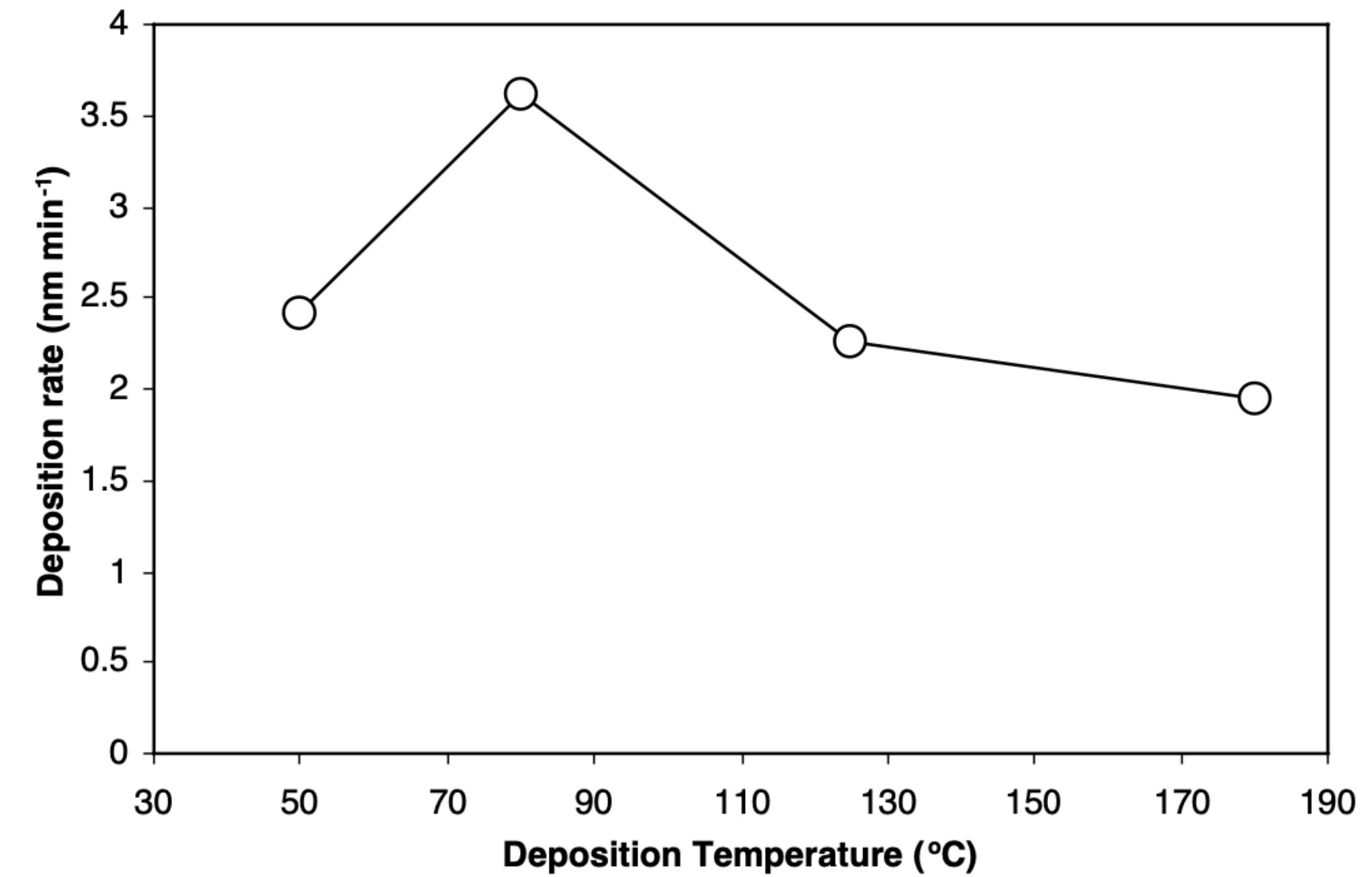
Target: Graphite 75mm diameter

Substrate: Silicon wafer pre-sputtered

Gas: Argon pure (99,99%)

Working pressure:  $10^{-3}$  Pa

Working Temperatures: 50, 80, 125 and 180 °C

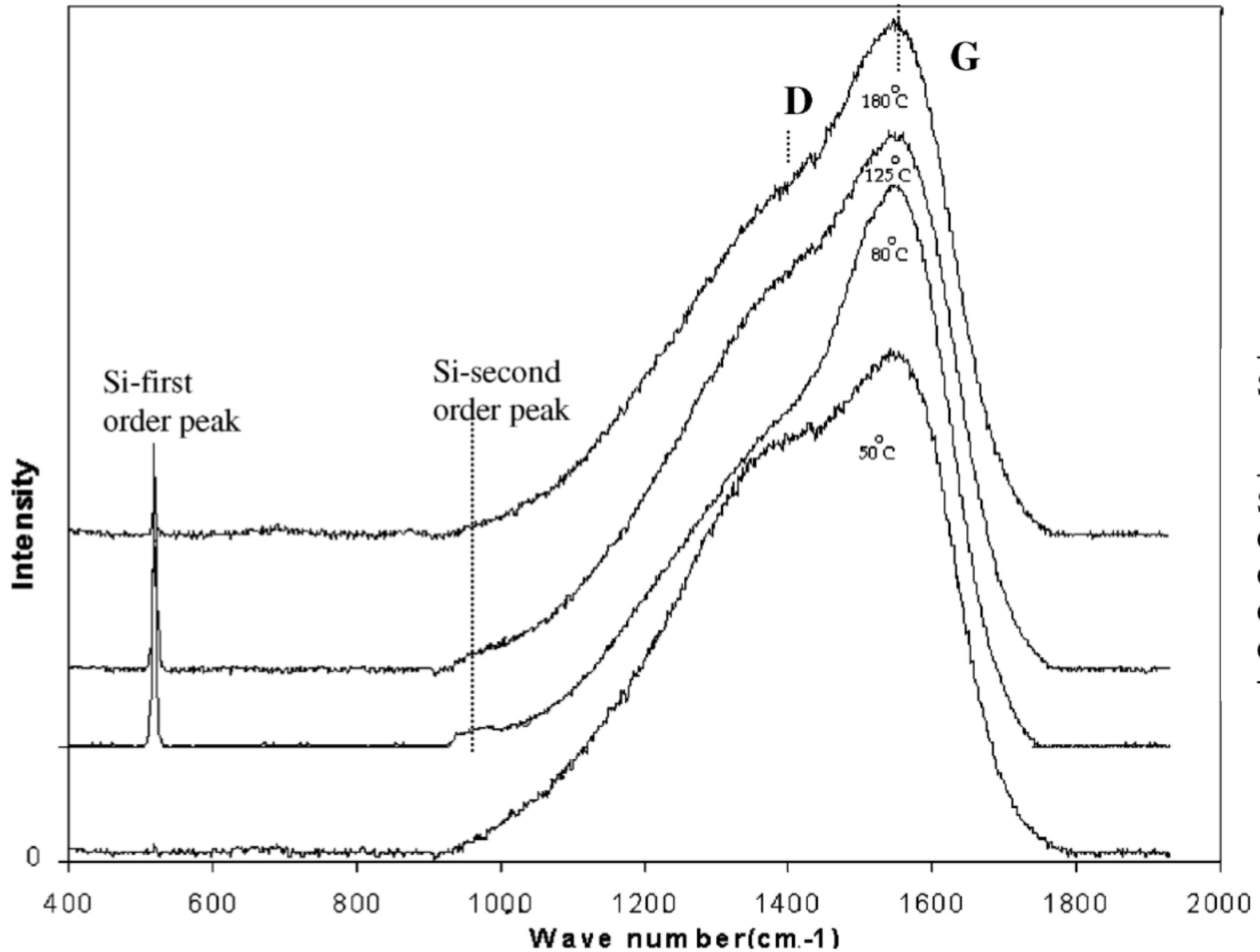


From 50 °C to 80°C → increase  
Higher 80 °C → decrease

# RAMAN SPETTROSCOPY



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Sample	Power (W)	Ar gas (Pa)	Temperature (°C)	Bonding properties		
				D peak (cm⁻¹)	G peak (cm⁻¹)	$I_d/I_g$
Silicon (100)	-	-	-	-	-	-
C-38	-	-	50	1386	1565	3.64
C-33	200	0.2	80	1350	1553	1.02
C-34			125	1345	1556	1.20
C-53			180	1347	1556	1.13

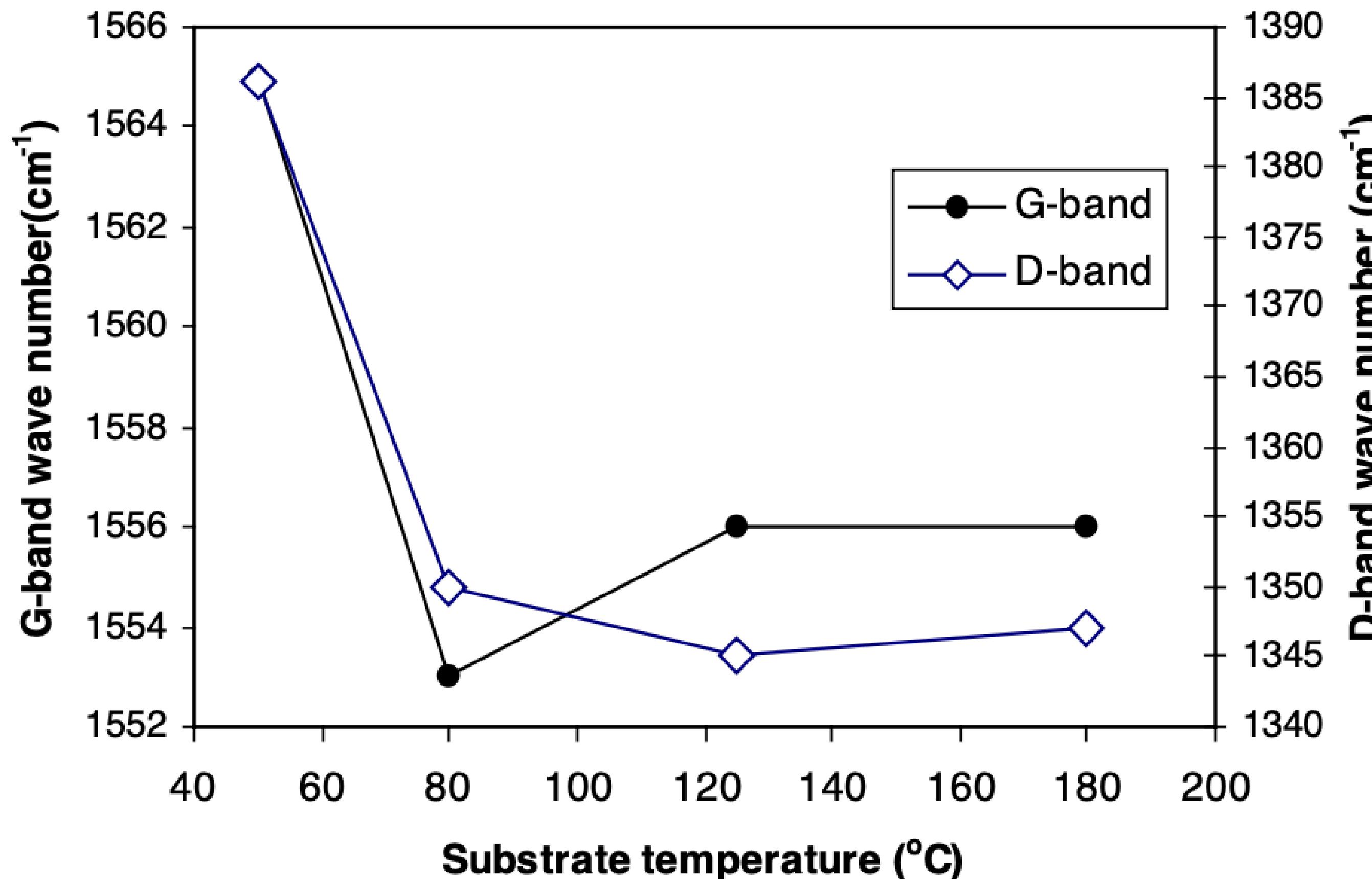
Experimental results for DLC films with different substrate temperatures using Raman spectroscopy

Raman spectra of the DLC films deposited at different substrate temperatures

# Beeman Model



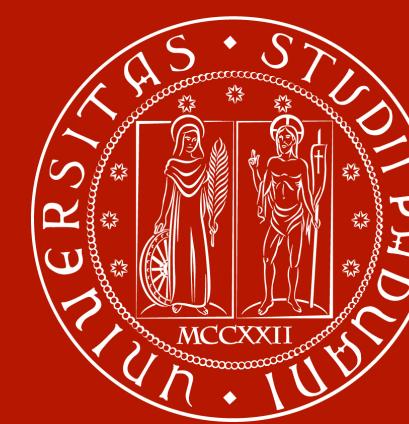
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**Beeman model to estimate sp<sup>3</sup>/sp<sup>2</sup> ratio  
from G peak position**

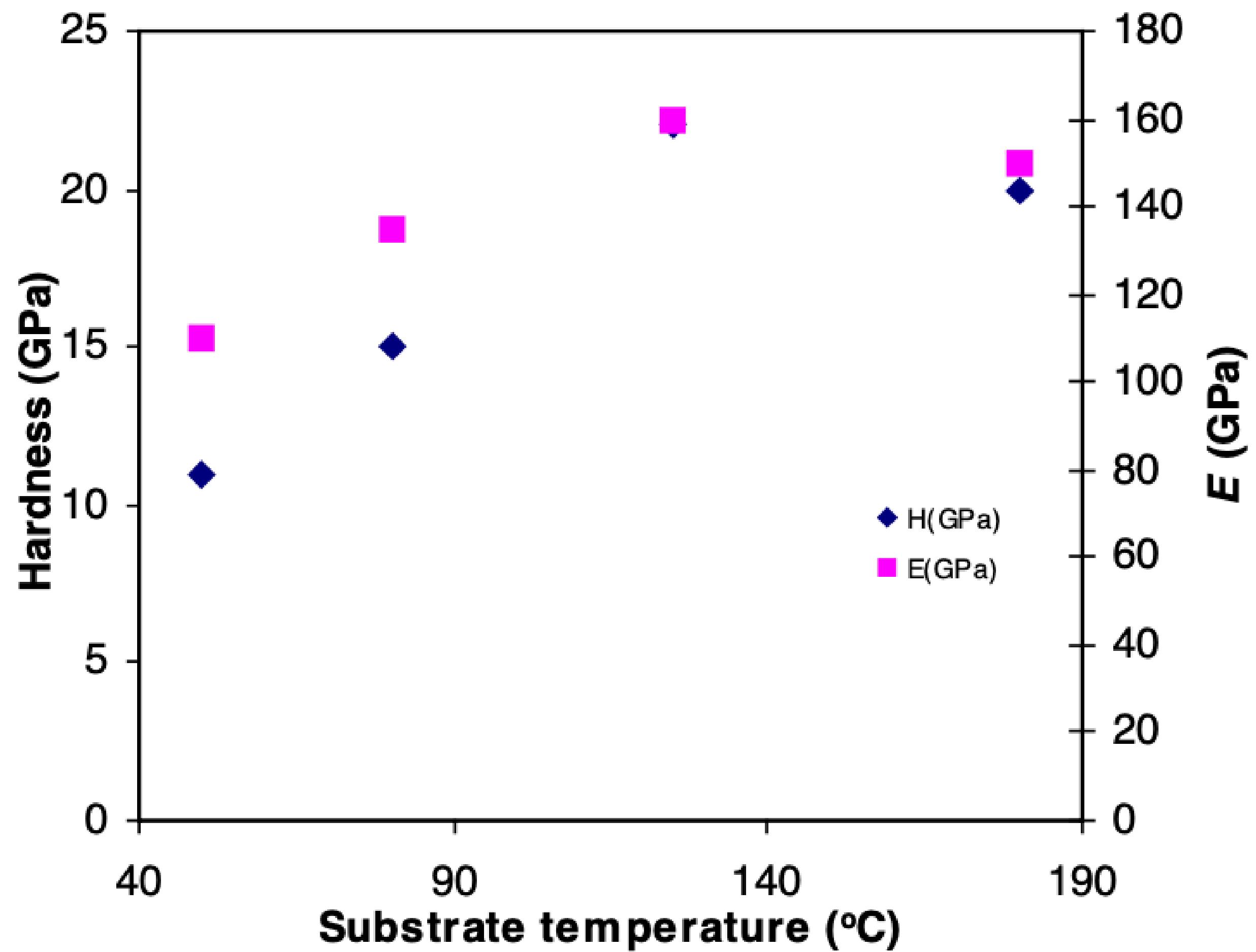
**From 50 °C to 80°C → sp<sup>3</sup> increase  
Higher 80 °C → sp<sup>3</sup> decrease**

# MECHANICAL PROPERTIES



## Vickers test + uniaxial traction test

Mechanical properties	
$H$ (GPa)	$E$ (GPa)
13	151
11	110
15	135
22	160
20	150

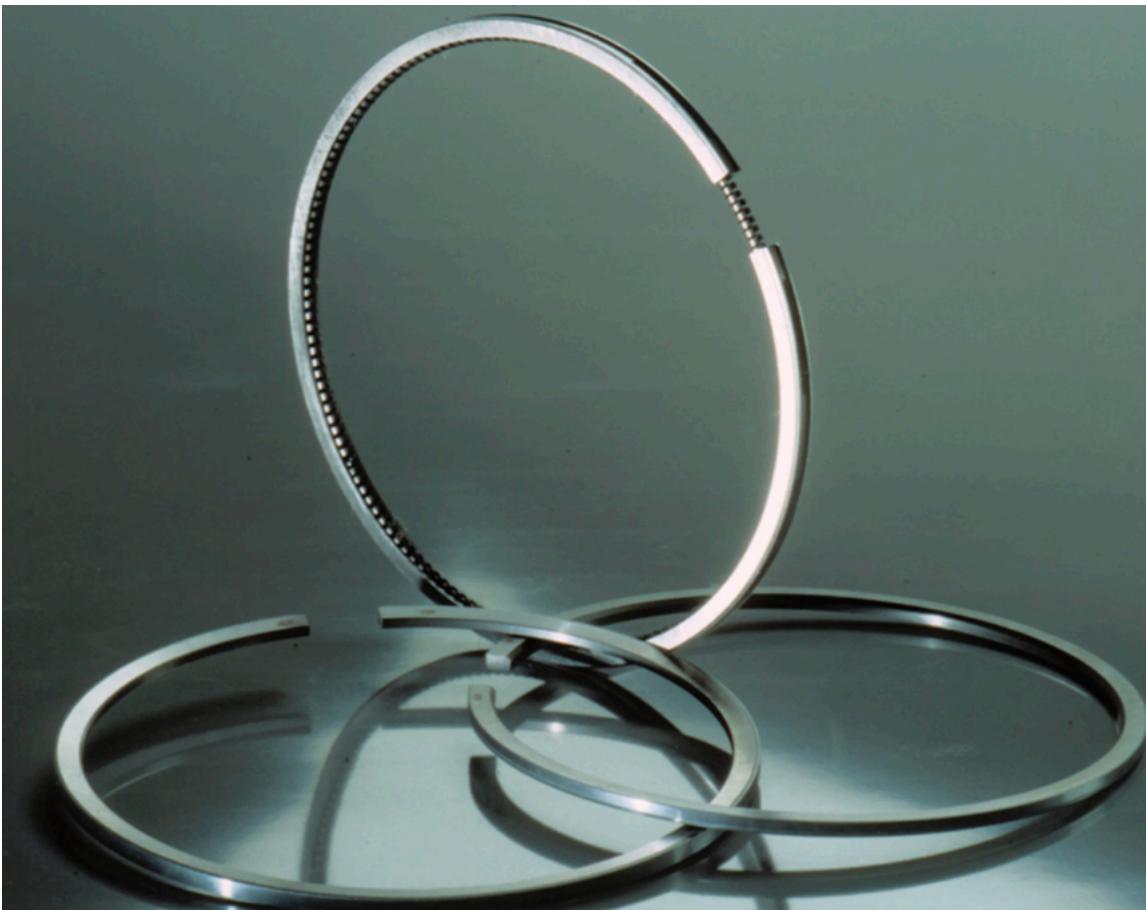


125°C higher order carbon atoms

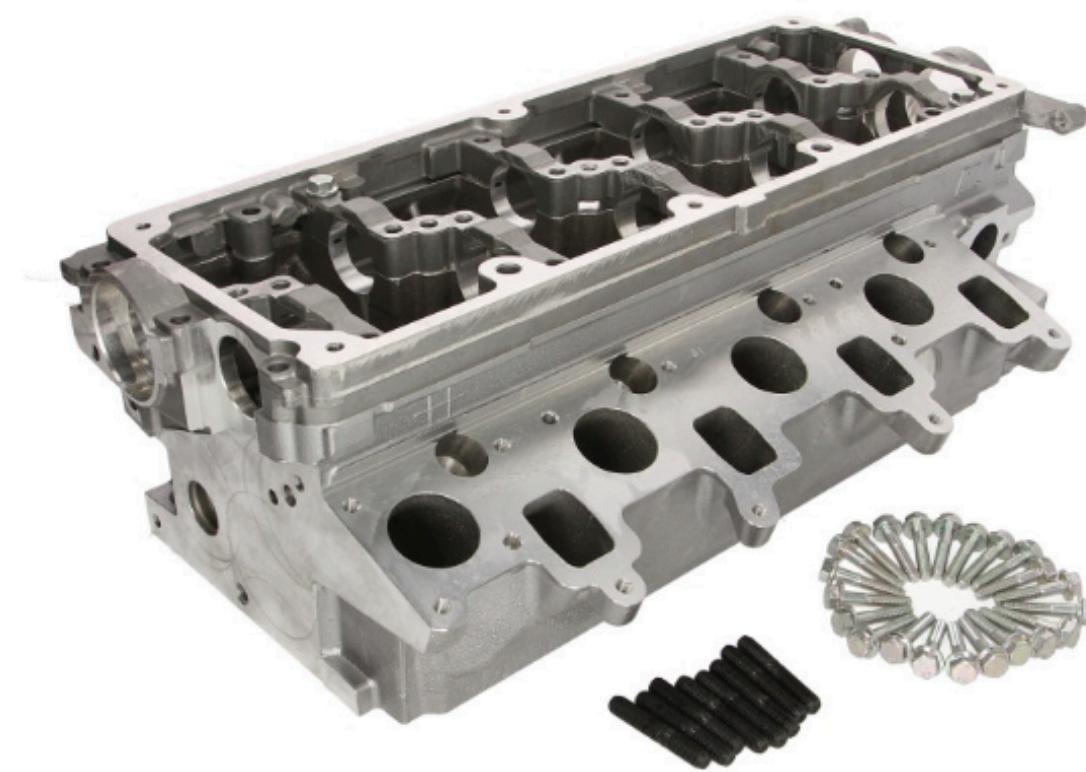
# MECHANICAL PROPERTIES



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**High hardness (H)**



**High elastic modulus (E)**

# Bibliography



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- **Fundamentals, overtones, and combinations in the Raman spectrum of graphite** Yasushi Kawashima Department of Mechanical Engineering, Faculty of Engineering, Tokai University, Hi ratsuka, Kanagaura 259-12, Japan
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